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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Sinn-Wen CHEN Confirmation No: 3281
Appl. No. : 10/657,273
Filed : September 9, 2003
Title : ELECTROMIGRATION EFFECT-INSIGNIFICANT ALLOYS
AND THE ALLOY'S DESIGNATING METHOD

TC/A.U. : 1742
Examiner : J. P. Sheehan

Docket No.: : CHEN3585/REF
Customer No: : 23364

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This is in response to the Official Action of January 5, 2006, in connection with the above identified application.

The Official Action is a Restriction Requirement in which it is urged that there are two separate and distinct inventions claimed in this application. Applicants elect the Group II invention consisting of claim 7, drawn to a method of designing an alloy, without traverse. Applicants reserve the right to file a divisional application on the non-elected invention at a later time.

In view of the election of the Group II invention, without traverse, an early and favorable action on the merits is now believed to be in order and is most respectfully requested.

Respectfully submitted,
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Response to Restriction Requirement.wpd
January 17, 2006